Femtosecond Laser Desorption of Thin Polymer Films from a Dielectric Surface

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Abstract: We desorb polymer films from fused silica with a femtosecond laser and characterize the results by atomic force microscopy. Our study as a function of beam geometry and energy reveals two ways of achieving spatially controlled nanodesorption.

1. Introduction

The use of femtosecond laser pulses at critical intensity, i.e. slightly above the threshold for nonlinear absorption, allows absorption that can be triggered in a sub-diffraction volume, opening doors to nanoscale machining [1]. Besides machining, the nanoscale desorption of surface layers has potential technical significance. However, the mechanisms involved in the absorption of the laser energy strongly depend on the laser intensity, and a small fluctuation of the latter can lead to large differences in the induced modifications of the material.

We show that the desorption of thin polymer films from fused silica can be controlled by tightly focusing the femtosecond laser beam through the substrate, thus desorbing from the back surface. We show two approaches to achieve this control: i) by focusing at the surface and optimizing the energy and number of pulses applied, and ii) by focusing inside the substrate and making use of the self-controlled deposition of energy by nonlinear absorption in the wide-band-gap material.

2. Experimental setup and methods

We performed desorption of a multilayered thin film of polymer with femtosecond laser pulse. The sample was made of a fused silica 25×25×0.22 mm microscope coverslip, on which we deposited 4 bilayers of Poly(allylamine hydrochloride) / Poly(sodium 4-styrenesulfonate). Prior to the deposition of the film, gold lines of 200 µm width and 100 nm thickness, each separated by 200 µm were deposited on the surface of the coverslip. Desorption was achieved in between the lines. The sample was positioned on three motorized translation axes. We used a Ti:Sa laser delivering pulses of 45 fs duration at a wavelength of 800 nm and a repetition rate of 50 Hz and we varied its energy by means of a polarizer and a half-wave plate. The energy fluctuations were on the order of 2% RMS.

Three objective lenses with 0.25, 0.40 and 0.95 numerical aperture (NA), respectively, were used to focus the laser beam onto the back surface of the sample. The position of the focus with respect to the sample surface was varied by moving the sample along the optical axis z.

We used the sharp edges of the gold lines for in situ measurements of the beam waist by the so-called knife-edge technique [2], which enabled us to determine both the focus position and the beam waist with a 0.1 µm precision.

3. Results

Direct desorption

The desorption experiment consisted in a matrix of irradiation sites separated by 3 µm each. In one direction, we varied the laser energy, while in the other direction, we varied the z-position of the focus. The observation of the matrix with AFM enabled characterization of the surface with nanometer resolution. When the energy was below the threshold for fused silica damage and above the threshold for desorption, we observed holes with sharp edges and reproducible 8 nm depth, clearly indicating that only the film was removed by the fs laser pulse. The diameter of the holes was at maximum when the focus was right at the surface, as shown in fig 1.a.

We found a threshold for desorption of 25 nJ using the NA 0.40 lens, which corresponds to an intensity of 8×10^12 W/cm^2 according the beam waist measurement. This threshold is by a factor of two lower than the threshold for non linear absorption in fused silica, which we measured by looking at the transmitted energy as a function of input energy of the focalized beam in the bulk, as done in previous work [3]. Even if this threshold is lowered...
because of the constructive interferences of the incident and reflected fields at the dielectric – air interface, we found that the absorption of energy still occurs directly in the film itself.

![Graph](image1.png)

**Fig. 1.** a) Diameter of the desorbed holes by 10 laser pulses as a function of focus position with respect to the surface for 7 and 8 nJ pulse energy, with NA 0.95 focusing lens. b) AFM image of the desorbed feature with 7 nJ. The black circle indicates the diameter at 1/e^2 of the beam.

The smallest feature observed was 150 nm in diameter (FWHM), using the NA 0.95 objective (see fig.1.b). However, these small holes were not reproducible using a single laser pulse, mainly due to the instabilities of the laser intensity.

To average out the intensity fluctuations and obtain reproducible desorption features, we increased the number of laser pulses per irradiation site. We found that the diameter increased as a function of the applied number of laser pulses, so that 10 pulses per site was a good tradeoff between small size and reproducibility. We could obtain reproducible 200 nm diameter desorbed holes, which is by a factor of 6 less than the beam diameter at 1/e^2.

**Substrate mediated desorption**

The second way of controlling the film desorption is by taking advantage of the nonlinear interaction inside the substrate. It has been shown that filamentation inside dielectrics leads to an elongated damage along the beam propagation axis with small radial dimension [4].

We focused the laser a few Rayleigh ranges back inside the substrate, with pulse energies above the absorption threshold and a power above the critical power for self-focusing. We found that for a specific position of the focus with respect to the surface, it is possible to induce desorption of the film without apparent damage of the substrate surface. In addition, this desorption becomes extremely reproducible even for laser energy variations as large as 30%. For instance, with NA 0.40, we could observe consistent holes of 500 nm diameter when varying the energy from 150 to 200 nJ. Although the features observed were bigger, we could achieve a better control and better reproducibility with single pulse irradiation than when focusing right at the surface.

4. **Conclusion**

We performed nanodesorption of polymer thin films from a fused silica substrate by tightly focusing a femtosecond laser on the sample back surface. On one hand, we showed that when working close to the desorption threshold, the substrate plays no role and the film can therefore be considered as free standing. This has potential for strong field interactions with two dimensional structures. On the other hand, we achieved spatial control by inducing filamentation in the substrate prior to desorption, substantially increasing the reproducibility. Both approaches allow desorption on scales below the self-diffraction limit.

5. **References**


